PTC/SB/08a (05-07)
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	Application Number		10517575	
NFORMATION DISCLOSURE STATEMENT BY APPLICANT	Filing Date		2004-12-09	
	First Named Inventor Victor		ictor Lu	
	Art Unit		2813	
Not for submission under 37 CFR 1.99)	Examiner Name	Monica D. Harrison-		
	Attorney Docket Numb	er	H0004019 68746 US - 4780	

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			Attorney Docket Number		er	H0004019.68746	US - 4780
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( Not for submission under 37 CFR 1.99)				Exami	ner Na	me	Moni	ica D. Harrison			
		Attorn	ey Docl	ket Numb	er	H0004019.68746	US - 4	780			
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Art Unit 2813 ( Not for submission under 37 CFR 1.99) Examiner Name ca D: Harrison H0004019 68746 US - 4780 Attorney Docket Number

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